

Quality and cost factors for LED sapphire wafer manufacturing

Fabiano Assi - 17.11.2012





Meyer Burger at a glance



Markets	Solar	Semiconductor	Sapphire & Optoelectronics
	Wafering - Cutting Technologies - Measuring Systems - Wafer Handling - Robotics and Automation - Diamond Wire Cell - Inspection Systems - Handling Systems - Coating Systems Module - Cell Connecting - Module Solutions - Lamination - Measurement Systems	Wafering - Cutting Technologies - Measuring Systems - Wafer Handling - Automation Systems	Wafering - Boule Handling - Boule/Core Preparation - Cutting Technologies - Measuring Systems - Wafer Handling - Wafer Inspection Systems - Automation Systems

Meyer Burger holistic approach





- ✓ Up- and Down-Stream process integration starting from Meyer Burger core competences:
 - Crystal handling and measurement
 - Core Gluing
 - Slicing
 - Cleaning and Quality Control
 - Consumables (in particular diamond wire)
 - Integration of third party machines
 - Optimization and process support along the whole process / value chain







Sapphire Slicing System





Processing factors examples



- 1. Quality
 - Crystal orientation \Rightarrow Wafer quality



- 2. Throughput
 - Slicing rocking angle \Rightarrow Cutting speed



- 3. Cost of Ownership
 - Slicing recipe





 \Rightarrow Wire performance

Example 1 – Wafer quality



3D core adjustment



Example 1 – Wafer quality



- Wafer quality showcase 2"
 - C to M accuracy ±0.03°
 - C to A accuracy ±0.03°
 - Best control of crystal orientation
 - Best control of crystal anisotropy for slicing operations
 - Perfect matching sapphire
 - glue beam combination







- Orientation before gluing important
- Tight tolerances for each process step

Process with 3D Core Adjustment:



- Reduced requirements on all steps more variation allowed
- Potential to eliminate grinding of Top/Tail surfaces

Example 1 – Wafer quality

- Wafer quality showcase 4"
 - Cutting time: 6.5 h
 - Wire: DMT 250 µm
 - Coolant: water based + additive
 - Pitch: 1.020 mm
 - Wafer measurement: HE-SIA-01



Sapphire Wafer-Measuring & Sorting-System: HE-SIA-01 Hennecke Systems GmbH, Germany



Example 2 – Throughput



- Slicing contact length influences the wafer quality
 - A relevant factor determining the slicing performance \Rightarrow Throughput





Example 2 – Throughput



 The tradeoff between contact length and wafer shape defines the best process.

- Wafer quality showcase 4"
 - Cutting time: 4.0 12.0 h
 - Rocking: 4° 12°
 - Wire: DMT 250 μm
 - Coolant: water based + additive
 - Pitch: 0.805 mm
 - Wafer measurement: HE-SIA-01



Example 3 – Cost of Ownership



- The slicing recipe influences the wire consumption
 - A relevant factor determining the slicing performance \Rightarrow CoO





Showcase Wire consumption 2"

Challenge

Reduce current wire consumption of 2.70 m/wfr

- Production environment
- Machine: DS265
- Wire: DMT 250 um wire

Approach

- Meyer Burger Process development
 - MB: Process Expertise
 - Customer: MC, operators and material
- One week program

Achievements

- 23 cuts done
- Wire consumption reduced to 2.17 m/wfr





Total Cost Savings

- ~20% less wire/wafer
- ~15% COO reduction

Showcase Wire consumption 4"



Challenge

Reduce current wire consumption of 16.0 m/wfr

- Production environment
- Machine: DS265
- Wire: DMT 250 um wire

Approach

- Meyer Burger Process development
 - MB: Process Expertise
 - Customer: MC, operators and material
- Three weeks program



Achievements

- 6 cuts done
- Wire consumption reduced to 12.5 m/wfr

Total Cost Savings

- ~ 25% less wire/wafer
- ~ 20% COO reduction

Showcase Wire consumption 6"



Challenge

Reduce current wire consumption of 70 m/wfr

- Production environment
- Machine: DS265
- Wire: DMT 250 um wire

Approach

- Meyer Burger Process development
 - MB: Process Expertise
 - Customer: MC, operators and material
- Four weeks program



Achievements

- Wire performance reduced to 42 m/wfr
- New recipes are used in production

Total Cost Savings

- ~ 40% less wire/wafer
- ~ 35% COO reduction

Showcase Cutting time 6"



Challenge

Improve throughput of 65'000 wafers/year

- Production environment
- Machine: DS265
- Wire: DMT 250 um wire

Approach

- Meyer Burger Process development
 - MB: Process Expertise
 - Customer: MC, operators and material
- Two weeks program

Bow and WARP values for 6" fast cuts



Achievements

- 55% reduction of cut time (24h to <11h)
- Increased output from 65k to 105k Wafer per year

Savings and Benefits

- ~2% cost savings per wafer
- >40'000 Wafers additional (per year)

Conclusions



Relevant system parameters Influence on performance - Crystal orientation – Wafer quality - Cutting speed - Throughput - Slicing rocking angle - Costs - Slicing recipe System approach Performance improvement up to 40%



Thank you for your attention !

Passionate about LED





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